



RACDV/ CHRI Workshop

Humanities Research with Impact

30th June 2009

10 a.m.-12 noon, Council Chamber, Main Building

The aim of this workshop is to raise awareness of the emerging impact agenda, and to provide an opportunity to discuss and explore its implications for Humanities Schools at Cardiff.

Who should attend?

The workshop is open to all who want to find out more about this topic, but would be particularly relevant to research administrators, research staff, and PGRs in humanities schools. The content will be tailored to Humanities Schools.

What will it cover?

The workshop will be split into two sessions, which participants can opt-in/out of.

A) The first session (10 - 10.35 a.m.) will be a presentation on 'Impact' from Rebecca Blackwell, Research Development Officer for Arts and Humanities in RACDV. The presentation will cover key messages around 'Excellent Research with Impact' emerging from DIUS and the AHRC and ESRC, as well as providing some practical examples and case studies in relation to impact from humanities disciplines.

B) The second session (10.45 - 12 noon) will be a participatory workshop, where attendees will be split into three groups to explore:

- i) Methods: possible ways of achieving impact from humanities research at Cardiff;
- ii) Recording impact: possible ways of capturing and collating evidence of impact; and
- iii) Grant-writing: practical tools to address the new AHRC and ESRC application requirements on impact.

What preparation might be useful?

No pre-existing knowledge is required, but please come willing to participation in discussions. Relevant background reading includes:

AHRC FAQs on Impact: <http://www.ahrc.ac.uk/FundingOpportunities/Documents/ImpactFAQ.pdf>

ESRC FAQs on Impact: <http://www.esrc.ac.uk/ESRCInfoCentre/Support/esrcexpectations/faq.aspx>

AHRC Impact Strategy: <http://www.ahrc.ac.uk/About/Policy/Documents/impact%20strategy.pdf>

Please RSVP by email to BlackwellRM@cf.ac.uk with an indication of which sessions you would like to attend (A, B or both), so that we can plan effectively for the workshop.